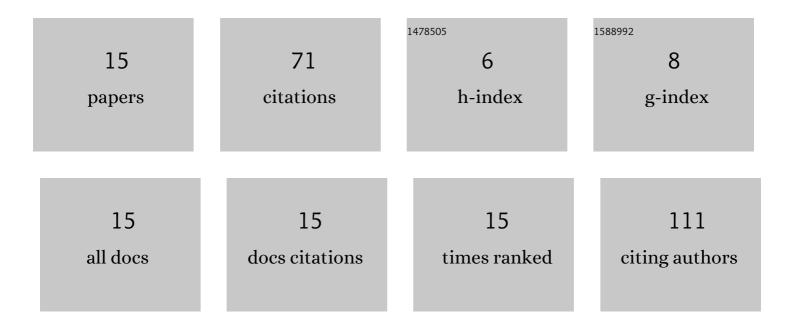
Valeri Dzhurkov

List of Publications by Year in descending order

Source: https://exaly.com/author-pdf/9413611/publications.pdf Version: 2024-02-01



#	Article	IF	CITATIONS
1	Selective photosensitivity of metal–oxide–semiconductor structures with SiOx layer annealed at high temperature. Journal of Materials Science: Materials in Electronics, 2020, 31, 17412-17421.	2.2	3
2	UV Sensitivity of MOS Structures with Silicon Nanoclusters. Sensors, 2019, 19, 2277.	3.8	7
3	Phase characterization and ethanol adsorption in TiO2 nanotubes anodically grown on Ti6Al4V alloy substrates. Journal of Alloys and Compounds, 2019, 798, 394-402.	5.5	5
4	Room temperature sensitivity of ZnSe nanolayers to ethanol vapours. Journal of Physics: Conference Series, 2019, 1186, 012023.	0.4	2
5	Investigation of resistive switching in SiO2 layers with Si nanocrystals. Journal of Physics: Conference Series, 2019, 1186, 012022.	0.4	2
6	Surface modification and chemical sensitivity of sol gel deposited nanocrystalline ZnO films. Materials Chemistry and Physics, 2018, 209, 165-171.	4.0	18
7	Resistive switching behavior of SiOxlayers with Si nanoparticles. Journal of Physics: Conference Series, 2017, 794, 012018.	0.4	0
8	Photoluminescence from 20 MeV electron beam irradiated homogeneous SiOxand composite Si-SiOxfilms. Journal of Physics: Conference Series, 2016, 764, 012018.	0.4	0
9	High energy electron-beam irradiation effects in Si-SiO _x structures. Journal of Physics: Conference Series, 2016, 682, 012012.	0.4	7
10	Application of Metal-Oxide-Semiconductor structures containing silicon nanocrystals in radiation dosimetry. Open Physics, 2015, 13, .	1.7	8
11	Structural, compositional and electrical characterization of Si-rich SiOx layers suitable for application in light sensors. Materials Science in Semiconductor Processing, 2015, 37, 229-234.	4.0	7
12	UV Dosimeters Based on Metal-Oxide-Semiconductor Structures Containing Si Nanocrystals. Sensor Letters, 2015, 13, 561-564.	0.4	2
13	Electrical conductivity and optical properties of tellurium-rich Ge-Sb-Te films. Journal of Physics: Conference Series, 2014, 558, 012046.	0.4	2
14	Spectroscopic studies of SiO _x films irradiated with high energy electrons. Journal of Physics: Conference Series, 2014, 558, 012045.	0.4	7
15	MOS Structures Containing Si Nanocrystals for Applications in UV Dosimeters. Key Engineering Materials, 0, 605, 380-383.	0.4	1